

Electrochemical Impedance Spectroscopy for Corrosion

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Introduction

There are 2 categories of electrochemical techniques: time domain and frequency domain [1].

Time domain :

- ▶ Voltammetry: $I = f(U)$.
- ▶ Chronoamperometry: $\Delta U, I(t)$.
- ▶ Zero Resistance Ammeter: $\int j_{gal} \cdot dt$.
- ▶ ...

Frequency domain:

- ▶ Electrochemical Impedance Spectroscopy: EIS.
- ▶ PhotoElectrochemical Impedance Spectroscopy: PEIS.

Advantages of EIS:

- ▶ Measurement in small perturbations (linearization).
- ▶ Different processes have different time constants.
- ▶ Large frequency range from μHz to GHz .

What is EIS?

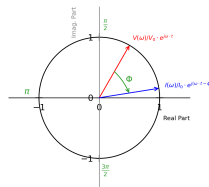
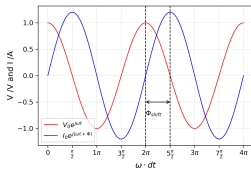
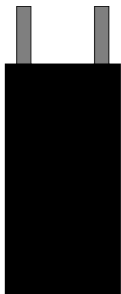
Black Box Approach

Assume a black box with terminals.

One applies a voltage and measures the current response (or vice versa).

Periodic signal with an angular frequency $\omega = 2\pi f$ with $0 \leq \omega < \infty$:

- ▶ Voltage $V(\omega) = V_0 e^{j\omega t}$
- ▶ Voltage $I(\omega) = I_0 e^{j\omega t - \Phi}$



Complex Impedance

The complex impedance is determined from the imposed voltage/current and the measured current/voltage through the Ohm's law:

$$Z(\omega) = \frac{V(\omega)}{I(\omega)} = \frac{V_0}{I_0} e^{j\Phi} = Z_0 e^{j\Phi}$$

Therefore:

- ▶ resistive behavior: $ReZ = Z_0 \cdot \cos \Phi$
- ▶ capacitive/inductive behavior $ImZ = Z_0 \cdot \sin \Phi$

Sometimes, the complex admittance $Y(\omega)$ can also be used which is defined as the inverse of the complex impedance $Z(\omega)$

$$Y(\omega) = \frac{1}{Z(\omega)}$$

Representations I

The impedance $Z(\omega)$ can be represented in two different ways:

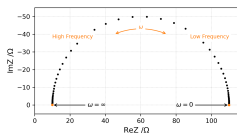
- ▶ Nyquist plot: represents the real and imaginary parts of $Z(\omega)$ using cartesian coordinates.
- ▶ Bode plot: shows the phase shift and magnitude changes in the range of applied frequencies.

The Bode plot has great advantages for observing phase changes. Therefore, it is useful for the study of sensors, filters, and transistors in electronic devices.

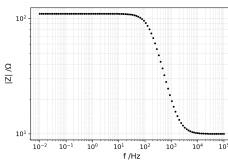
The Nyquist plot provides a better insight into the possible mechanisms.

Representations II

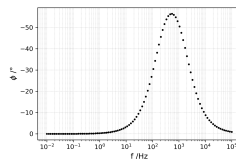
Among these two types of representations, the Nyquist plot is more often used to analyze the characteristics of electrochemical processes occurring during corrosion.



Nyquist Plot



Bode Plot - Magnitude



Bode Plot - Phase

Series and parallel connections

Series connections: $Z_1 - Z_2 - \dots - Z_n$

$$Z_{eq} = \sum_{i=1}^n Z_i$$

Parallel connections: $Z_1 / Z_2 / \dots / Z_n$

$$\frac{1}{Z_{eq}} = \sum_{i=1}^n \frac{1}{Z_i}$$

$$Z_{eq} = \left(\sum_{i=1}^n \frac{1}{Z_i} \right)^{-1}$$

Equivalent Circuit Models

The circuit model for EIS consists of a combination of electrical circuit elements[2]:

- ▶ ideal elements:
 - ▶ resistors (R)
 - ▶ capacitors (C)
 - ▶ inductors (L)
- ▶ nonideal capacitor-like element: Constant Phase Element (CPE or Q)
- ▶ diffusion elements:
 - ▶ semi-infinite Warburg (W)
 - ▶ finite length warburg (W_δ or O or FLW)
 - ▶ finite space warburg (W_m or T or FSW)

The circuit model represents the entire system.

The aim is to build an optimal circuit model that is physically meaningful and minimizes the number of variables [3].

Circuit Elements

R (Resistor): $Z(\omega) = R$

C (Capacitor): $Z(\omega) = \frac{1}{jC\omega}$

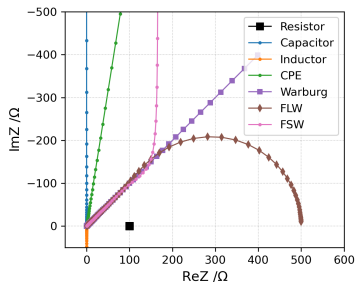
L (Inductor): $Z(\omega) = jL\omega$

Q (CPE⁴): $Z(\omega) = \frac{1}{Q(j\omega)^\alpha}$

W (SIW¹): $Z(\omega) = \frac{\sigma}{\sqrt{\omega}} \cdot (1 - j)$

W_δ (FLW²): $Z(\omega) = \frac{R_\delta \cdot \tanh \sqrt{j\omega\tau}}{\sqrt{j\omega\tau}}$

W_m (FSW³): $Z(\omega) = \frac{R_m \cdot \coth \sqrt{j\omega\tau}}{\sqrt{j\omega\tau}}$



¹SIW = Semi-Infinite Warburg

²FLW = Finite Length Warburg

³FSW = Finite Space Warburg

⁴CPE = Constant Phase Element

Circuit Elements and Physical Parameters

Resistors can be linked to resistivity or kinetics [4]

$$R = \rho \cdot \frac{\delta}{A}$$

$$R = \frac{RT}{FAj_0(\alpha_a + \alpha_c)} = \frac{RT}{AF^2 k^0 K_c(\alpha_a + \alpha_c)}$$

Capacitors can be linked to layer thickness:

$$C = \frac{\epsilon \epsilon_0 A}{\delta}$$

Warburg elements can be linked to diffusion

$$\sigma = \frac{RT}{Az^2 F^2 \sqrt{2}} \cdot \left(\frac{1}{\sqrt{D} C_O^*} + \frac{1}{\sqrt{D} C_R^*} \right)$$

$$R = \frac{RT}{Az^2 F^2 \sqrt{2}} \cdot \frac{\delta}{DC^*}$$

$$\tau = \frac{\delta^2}{D}$$

Coupling with other electrochemical techniques helps for determining all necessary parameters.

R : resistance [Ω]

ρ : resistivity [$\Omega \cdot m$]

δ : thickness [m]

A : Area [m^2]

j_0 : exchange current density [$A \cdot m^{-2}$]

k^0 : kinetics constant [$m \cdot s^{-1}$]

α_a : anodic transfer coefficient

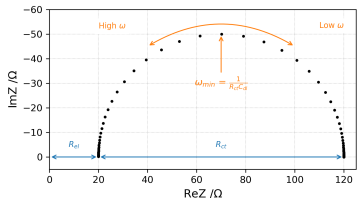
α_c : cathodic transfer coefficient

ϵ : relative permittivity

ϵ_0 : vacuum permittivity [$F \cdot m^{-1}$]

C^* : bulk concentration [$mol \cdot m^{-3}$]

C_{dl} : double layer capacitance



Randles Circuit

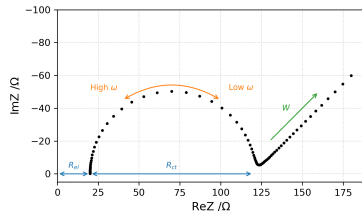
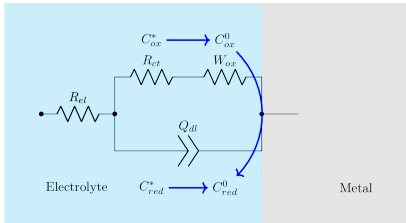
Reflects electrochemical reaction controlled by kinetics and diffusion [5].

R_{el} : electrolyte resistance

R_{ct} : charge transfer resistance

C_{dl} : double layer capacitance

W : semi-infinite diffusion

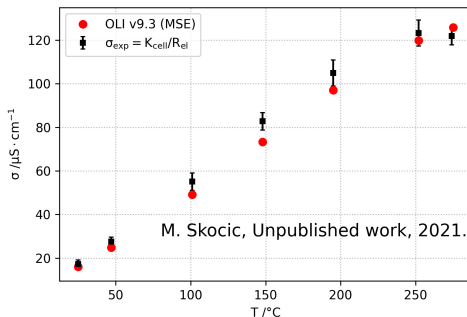


Conductivity vs Temperature

EIS can be used to estimate the electrolyte conductivity at different temperatures.

A calibration step is necessary at room temperature in order to define the cell constant: $\kappa = A/l$

Electrolyte containing $0.2 \text{ mmol} \cdot \text{L}^{-1} \text{ LiOH}$ and $63 \text{ mmol} \cdot \text{L}^{-1} \text{ H}_3\text{BO}_3$.

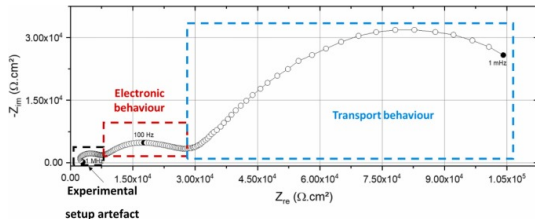


Corrosion mechanisms

2 domains are usually observed [6]:

- ▶ electronic contribution ($1\text{Hz} < f < 20\text{kHz}$)
- ▶ mass transfer contribution ($f \leq 1\text{Hz}$)

Relative amplitude of both contributions vary according to the limiting corrosion mechanism.

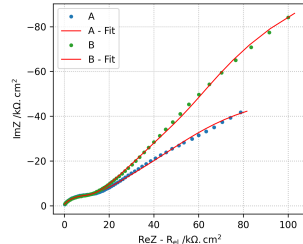
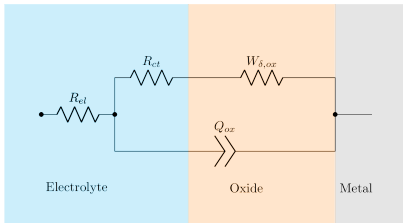


Equivalent Circuit

For alloy forming passive layers, the diffusion in the electrolyte is much faster than in the oxide.

The limiting processes, most of the time, occur in the oxide layer

- ▶ electronic contribution
- ▶ mass transfer contribution



Numerical Fitting

Numerical fitting using CNLS (Complex Nonlinear Least Squares) allows to determine the values of the electrochemical parameters for each circuit element [3].

Parameters such as effective capacitance, oxide thickness and diffusion coefficient can be computed.

Name	A	B
R_{el}	31 ± 1	99 ± 2
R_{ct}	190 ± 20	280 ± 2
W	3000 ± 400	5000 ± 300
n	0.36 ± 0.01	0.49 ± 0.01
τ	120 ± 40	62 ± 5
$Q_{ox} \cdot 10^6$	56 ± 8	102 ± 8
a_{ox}	0.69 ± 0.02	0.60 ± 0.01
$\delta(\mu m)$	0.10 ± 0.03	0.15 ± 0.05
$D \cdot 10^{12}(cm^2 \cdot s^{-1})$	1.7 ± 0.5	1.9 ± 0.9

$$Z_{CPE}(\omega) = \frac{1}{Q(j\omega)^\alpha}$$

$$C = Q^{1/\alpha} \cdot R_{ct}^{\frac{\alpha-1}{\alpha}} = \frac{\epsilon\epsilon_0 A}{\delta}$$

$$Z_{W_\delta}(\omega) = R_\delta \frac{\tanh \sqrt{(j\omega\tau)}}{\sqrt{j\omega\tau}}$$

$$\tau = \frac{\delta^2}{D}$$

Conclusions

EIS technique

- ▶ EIS is a frequency domain electrochemical technique with small perturbations (linearization)
- ▶ The circuit model represents the entire system
- ▶ The objective is to build an optimal circuit model that is physically meaningful and minimizes the number of variables.
- ▶ Evaluation of model with equivalent circuits and numerical fitting (CNLS)

Applications

- ▶ Qualitative analysis of corrosion mechanism by observing the Nyquist plots for different alloys
- ▶ Quantitative analysis for estimating the corrosion current densities
- ▶ Quantitative analysis for computing physical parameters such as diffusion coefficients
- ▶ Computation of electrolyte conductivity with respect to temperature

Difficulties

- ▶ Noisy data at high temperature
- ▶ Choice of the equivalent circuit
- ▶ Propagation of errors on computed parameters

References I

- [1] A. J. Bard and L. R. Faulkner, *Electrochemical Methods: Fundamentals and Applications*, 2nd ed. New York: John Wiley & Sons, Inc., 2001.
- [2] M. E. Orazem and B. Tribollet, *Electrochemical Impedance Spectroscopy*. Wiley, Feb. 2008.
- [3] B. Boukamp, "A Nonlinear Least Squares Fit Procedure for Analysis of Immittance Data of Electrochemical Systems," *Solid State Ionics*, pp. 31–44, 1986.
- [4] E. Barsoukov and J. Macdonald, *Impedance Spectroscopy: Theory, Experiment, and Applications*, 2nd ed. Hoboken, NJ, USA: John Wiley & Sons, Inc., 2005.
- [5] A. C. Lazanas and M. I. Prodromidis, "Electrochemical Impedance Spectroscopy – A Tutorial," *ACS Meas. Sci. Au*, vol. 3, no. 3, pp. 162–193, Jun. 2023.
- [6] D. Peyret, D. Kaczorowski, M. Skocic, B. Tribollet, and V. Vivier, "Electrochemical and Modelling Study of ZrNbO Alloys Aged under High Temperature and High Pressure PWR Simulated Conditions," *Corrosion Science*, p. 111505, Sep. 6, 2023.